

Notice on revised existing Patents Forms under the new patent system

Upon the commencement of the Patents (Amendment) Ordinance 2016 (“Amendment Ordinance”) and the Patents (General)(Amendment) Rules 2019 (“Amendment Rules”) on **19 December 2019**, some of the existing Patent Forms will be revised. The draft version of the proposed revised forms is [attached](#) for advance information.

2. Most of the proposed revisions are concerned with the textual changes to the references to the provisions of the Patents Ordinance Cap. 514 and the Patents (General) Rules Cap. 514C as amended by the Amendment Ordinance and the Amendment Rules respectively.
3. As far as the data fields of the forms are concerned, we wish to highlight the proposed revisions to the following parts of Patents Forms P6 and P10:

Revised Form P6

- Part 04: replacement of the existing details with the addition of the data fields in respect of the number of independent claims
- Part 07: replacement of the existing details with the addition of the data fields in respect of the statement of reference to an earlier specified application

Revised Form P10

Part 04(b): replacement of the existing details with the addition of the data field “Which year are you paying for the renewal? (For standard patent only)” for facilitating filers to pay the appropriate fees according to the 3-tier progressive annual renewal rates for standard patents, an example of which is [attached](#) for reference.

The Patents Registry
Hong Kong Special Administrative Region
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